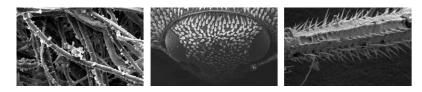
#### **Cube Series / Genesis Series / Veritas Series**

Navigate, Explore, ... and Discover In Every Research Area





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www.emcrafts.com



Genesis-2020

EMCRAFTS

# **High-Performance** Scanning Electron Microscope

Cube Series / Genesis Series / Veritas Series Navigate, Explore, ... and Discover In Every Research Area



### Navigate, Explore, ... and Discover In Every Research Area

High-Performance Scanning Electron Microscope

- BSE

**Cube Series / Genesis Series / Veritas Series** Navigate, Explore, ... and Discover In Every Research Area

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**03** Compact SEM [Genesis-Series]

04 Big Chamber SEM [Veritas-Series]

05 Software

#### 06 Optional Device

- EDS

- Coater

- Holder

- Filament

- Critical Point Dryer

- Freeze Dryer

- Cool Stage

- Polishing Machine

- Mounting Machine

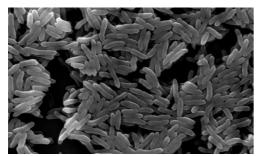
- 3D Reconstruction SW

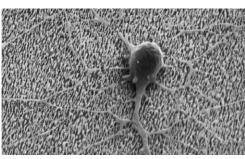


# **01 Applications**



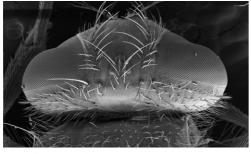
Life Science

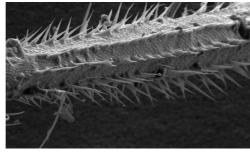




Bacteria

Neuron





Insect(Fly's head)

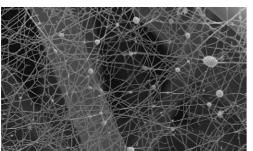
Insect(Fly's leg)



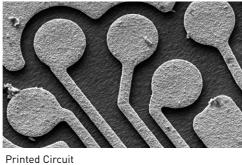
### Electronics

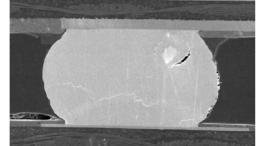


Wire bonding



Nano Fiber

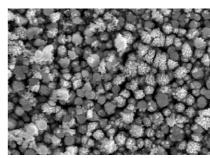




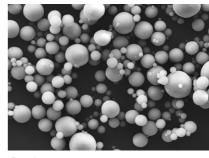
Semiconductor Package



Material Science



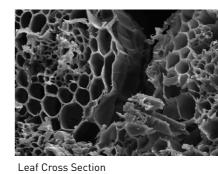
m Oxide

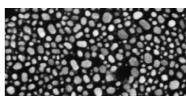


Powder



Natural Resource

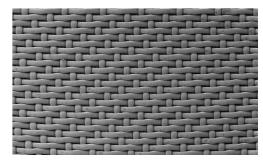




Gold Powder

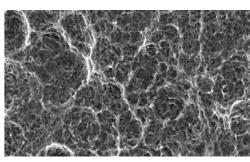
### 





Fabric



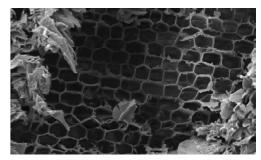


Dental Implant









Cross section of a tree

## **02 Tabletop SEM** Cube-Series

- Most Affordable and Portable
- Full 5-Axis Euccentric Stage
- Integrated EDS System

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Magnification	x20 ~ x200,000
Stage	X,Y : 40mm / Z : 5~20mm / T :-20~20° / R : 360°
Maximum Sample Size	60mm(H), 30mm(V)





### Installation Eastarin



**Space Efficiency** 

Services directions.

**5-Axis Euccentric Stage** 

Cube-series is the only Tabletop SEM which provides 5-axis euccentric stage(motorized or manual) in the world. Euccentric tilt is essential for 3D reconstruction function.

Cube-series is most compact Tabletop SEM in the world for its portability and space

efficiency. Users can move their SEM by themselves by following the Customer

### More Affordable Solution

Each laboratory can own its SEM and EDS system on its budget. EmCrafts' Cubeseries is a highly customizable system so that each laboratory can configure its own system. Please contact our sales department for your requirements.

### 

### **CUBE-Series** specification

Model	Cube-1000	Cube-1100	Cube-1000A	Cube-1100A				
Stage	<b>5-axis Manual</b> X,Y : 40mm (-20mm Z : 5 ~ 20mm / T : -20		<b>3-axis Motorized</b> X,Y : 40mm (-20mm ~ 20mm) / R : 360° <b>2-axis Manual</b> Z : 5 ~ 20mm / T : -20 ~ 20°					
Variable Pressure	Х	0	Х	0				
Vacuum Mode	High Vacuum only (‹9×10 <sup>-3</sup> Pa)	High Vacuum Mode (‹9×10 <sup>-3</sup> Pa) Low Vacuum Mode (10~230Pa)	High Vacuum only (‹9×10 <sup>-3</sup> Pa)	High Vacuum Mode (‹9×10 <sup>-3</sup> Pa) Low Vacuum Mode (10~230Pa)				
Vacuum System	-Turbo molecular pu -Rotary vane pump	ully Automated Evacuation System Furbo molecular pump (Vacuum ready within 3 minutes) Rotary vane pump Electrical valve system						
Electron Gun	Precentered Tungste	n Filament						
Detector	SE (ET-type)	SE (ET-type) BSE (4channel, Semiconductor)	SE (ET-type)	SE (ET-type) BSE (4channel, Semiconductor)				
Resolution	5.0nm (SE Image)	5.0nm (SE Image) 6.0nm (BSE Image)	5.0nm (SE Image)	5.0nm (SE Image) 6.0nm (BSE Image)				
Magnification	x20 ~ x200,000							
Acceleration Voltage	500V ~ 30kV							
Objective IRIS	20/20/50/100µm (Var	20/20/50/100µm (Variable aperture)						
Image Shift	±50µm							
Maximum Sample Size	Horizontal: 60mm, V	Horizontal: 60mm, Vertical: 30mm						
Advanced Scan Mode	Dynamic Focus, Poir	t & Line Scan, Tilt Compensation						
Working Distance	0~20mm							
Automatic Function	Auto Brightness/Cor	trast, Auto Focus, Auto Gun Alignm	nent, Auto Saturation, A	Auto Filament / Bias				
Image Format	JPG, TIFF, BMP, PN	JPG, TIFF, BMP, PNG						
Display Mode	Preview Mode : 800x Slow Mode : Applicat	Focus Mode : 320x240 pixel, Resizable Preview Mode : 800x600 Slow Mode : Applicable to both preview and focus mode Photo Mode : Up to 3200x2400						
Dimension(mm)	- Main System : 400(	- Main System : 400(W) x 600(D) - Main System : 400(W) x 500(D) x 580(H) - Control Box : 500(W) x 260(D) x 370(H)						
Supplied Accessories		Factory-centered Filament Cartridge 1box(10units), Specimen Mounts 1box(10units), Tweezer, Carbon Tape, Hex. Driver 0.89mm (1 ea.), Hex. T Wrench 2.5mm (2 ea.)						
Operation Device		Windows 10-based All-in-One 21.5" Workstation -100% controlled by keyboard and mouse						
Optional Devices		_aB&/CeB& upgrade   3D Imaging -in-one Model of SEM-EDS)   E-bea	am Lithography					
Power Supply	Single Phase : 100 ~	240VAC, 50/60Hz, 1kVA						

## **03 Compact SEM** Genesis-Series

- 5-Axis Euccentric Stage
- More Value in Less Space
- Straightforward & Intuitive Manual Stage (Genesis-1000 / 1100)
- More Versatile 5-Axis Motorized Stage (Genesis-2020 / 2120)
- Observation of Non-Conductive Sample (Genesis-1100 / 2120)

Genesis series is a high-performance W-filament SEM with x300K magnification and 3nm resolution.

High performance and versatility are integrated in a stylish design which is the most compact of the world in the same category.

EmCrafts-Patented vacuum system enables faster specimen exchange. (within 3min.)

Universal extension ports are available for future upgrade and user customization.

Due to factory-centered filament cartridge, filament exchange is easy and quick.

Images are saved in various formats and can be easily restored for annotation simply by clicking on the thumbnails.



### **Cost-Effectiveness**

• Genesis series are most affordably priced • Perfect solution for any laboratory

### **Easy Maintenance**

- Filament Burn out Notification
- Precentered Filament Only 1~2 Minutes are Required for a Filament Replacement
- Remote Diagnostics Electrical Checkpoints are Probed and Reported





Genesis 10	00/1100
------------	---------

- Intuitive 5-axis manual euccentric stage on Genesis-1000/1100 provides easy and straightforward way to move specimens.
- Variable pressure capability of Genesis-1100 enables users to observe non-conductive samples such as biological samples.

Magnification	x10 ~ x300,000
Stago	X,Y : 40mm / Z : 5~45mm /
Stage	T :-20~90°/ R : 360°
Maximum Sample Size	96mm(H), 50mm(V)

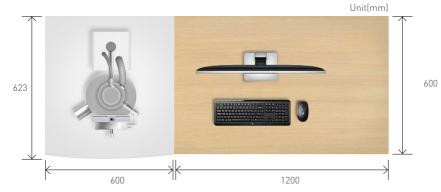
### **Genesis** 2020/2120

- Genesis-2020/2120 provides 5-axis motorized euccentric stage in the same compact design.
- Intuitive "Point & Go" operation enables effortless stage movement in a quick manner.
- Position save and restore function is useful especially for multi-specimen mount.

Magnification	x10 ~ x300,000
Stage	X : 90mm, Y : 60mm / Z : 5~60mm /
	T :-20~90°/ R : 360°
Maximum Sample Size	150mm(H), 60mm(V)



### Installation Footprint



### **GENESIS-Series** specification

Model	Genesis-1000	Genesis-1100	Genesis-2020	Genesis-2120			
Stage	5-axis Manual X : 40mm (-20mm ~ 20mm) Y : 40mm (-20mm ~ 20mm) Z : 5 ~ 45mm T : -20° ~ 90° R : 360°		5-axis Motorized X : 90mm (-45mm ~ 45mm) Y : 60mm (-30mm ~ 30mm) Z : 5 ~ 60mm T : -20 ~ 90° R : 360°				
Variable Pressure	Х	0	Х	0			
Vacuum Mode	High Vacuum only (<9×10 <sup>-3</sup> Pa)	High Vacuum Mode (<9×10 <sup>-3</sup> Pa) Low Vacuum Mode (10~230Pa)	High Vacuum only (<9×10 <sup>-3</sup> Pa)	High Vacuum Mode (<9×10 <sup>-3</sup> Pa) Low Vacuum Mode (10~230Pa)			
Vacuum System							
Electron Gun	Precentered Tungs	ten Filament					
Detector	SE(ET-type)	SE(ET-type) BSE(4channel, Semiconductor)	SE(ET-type)	SE(ET-type) BSE(4channel, Semiconducto			
Resolution	3.0nm (SE Image)	3.0nm (SE Image) 5.0nm (BSE Image)	3.0nm (SE Image)	3.0nm (SE Image) 5.0nm (BSE Image)			
Magnification	x10 ~ x300,000						
Acceleration Voltage	200V ~ 30kV						
Objective IRIS	20/20/50/100µm( Va	ariable aperture)					
Image Shift	±50µm						
Maximum Sample Size	Horizontal : 96mm,	Vertical : 50mm	Horizontal : 150mr	n, Vertical : 60mm			
Advanced Scan Mode	Dynamic Focus, Po	int & Line Scan, Tilt Compensatio	on				
Working Distance	0~45mm		0~60mm				
Automatic Function	Auto Brightness/Co	ontrast, Auto Focus, Auto Gun Alig	gnment, Auto Satura	tion, Auto Filament / Bias			
Image Format	JPG, TIFF, BMP, PN	G					
Display Mode	Preview Mode : 800	able to both preview and focus m	ode				
Dimension(mm)	- Main System: 600	sion : 1800(W) x 600(D) (W) x 623(D) x 1350(H), 130Kg 4(W) x 134(D) x121(H), 22Kg					
Supplied Accessories		ament Cartridge 1box(10units), Spe (1 ea.), Hex. T Wrench 2.5mm (2 ea.		Ounits), Tweezer, Carbon Tape,			
Operation Device		Windows10 -based All-in-One 21.5" Workstation -100% controlled by keyboard and mouse					
Optional Devices	EBSD[Electron Back Scattered Diffraction] EDS[Energy Dispersive Spectroscopy] WDS[Wavelength Dispersive Spectroscopy] CL[Cathodoluminescent] Imaging Chamber Camera LaB&/CeB& Upgrade 3D Imaging Raman Spectroscopy E-beam Lithography						

# **04 Big Chamber SEM** Veritas-Series

- High Performance and Productivity
- Large Scale Stage Movement

Veritas-series has 5-Axis euccentric motorized stage to provide easier measurement of large scale samples.

Magnification	x10 ~ x300,000
Stage	X,Y : 120mm / Z : 5~65mm / T :-20~90°/ R : 360°
Maximum Sample Size	210mm(H), 65mm(V)

### **Application**



Large Samples Analysis Veritas-series can analyze large-scale samples conventional SEMs cannot. ex : Wafer, disk

Non-destructive Samples Analysis Able to analyze samples without cutting ex : PCB, Semiconductor pattern Analysis

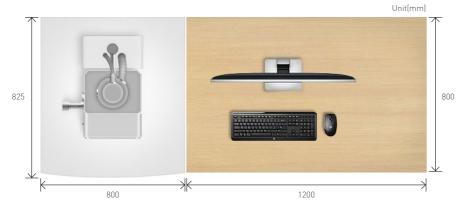






Heavy Samples Analysis Able to analyze heavy samples up to 2kg ex : Rock, Iron Ore





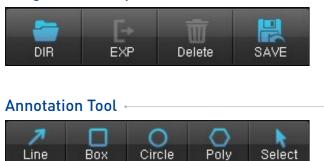
### **VERITAS-Series** specification

Model	Veritas-3000	Veritas-3100			
Stage Type	<b>5-axis Motorized</b> X,Y : 120mm(-60mm~60mm) Z : 5~65mm T : -20°~90° R : 360°				
Variable Pressure	Х	0			
Vacuum Mode	High Vacuum Mode (<9×10 <sup>-3</sup> Pa)	High Vacuum Mode (<9×10 <sup>-3</sup> Pa) Low Vacuum Mode(10 ~ 230Pa)			
Vacuum System	Fully Automated Evacuation System - Turbo molecular pump (Vacuum ready within 3 - Rotary vane pump - Electrical valve system	minutes)			
Electron Gun	Precentered Tungsten Filament				
Detector	SE Detector	SE Detector BSE Detector (4channel, Semiconductor)			
Resolution	3.0nm (SE Image)	3.0nm (SE Image) 5.0nm (BSE Image)			
Magnification	x10 ~ x300,000				
Acceleration Voltage	200V ~ 30kV				
Objective IRIS	20/20/50/100µm (Variable aperture)				
Image Shift	±50µm				
Maximum Sample Size	Horizontal: 210mm, Vertical: 65mm				
Advanced Scan Mode	Dynamic Focus, Point & Line Scan, Tilt Compens	ation			
Working Distance	0 ~ 65mm				
Automatic Function	Auto Brightness/Contrast, Auto Focus, Auto Gun Alignment, Auto Saturation, Auto Filament / Bias				
Image Format	JPG, TIFF, BMP, PNG				
Display Mode	Focus Mode : 320x240 pixel, Resizable Preview Mode : 800x600 Slow Mode : Applicable to both preview and focus Photo Mode : Up to 3200x2400	; mode			
Dimension(mm)	Installation Dimension : 2000(W) x 800(D) -Main System : 800(W) x 825(D) x 1500(H), 200kg -Rotary Pump : 454(W) x 134(D) x 212(H), 22kg				
Supplied Accessories	Factory-centered Filament Cartridge 1box(10units), Specimen Mounts 1box(10units), Tweezer, Carbon Tape, Hex. Driver 0.89mm (1 ea.), Hex. T Wrench 2.5mm (2 ea.)				
Operation Device	Windows 10-based All-in-One 21.5" Workstation	1 100% controlled by keyboard and mouse			
Optional Devices	Chamber Camera   LaB&/CeB& upgrade 3D Imaging   Raman Spectroscopy   EDS[Energy Dispersive Spectroscopy] EBSD[Electron Back Scattered Diffraction]   WDS[Wavelength Dispersive Spectroscopy] CL[Cathodoluminescence] Imaging   E-beam Lithography				
Power Supply	Single Phase : 100 ~ 240VAC, 50/60Hz, 1kVA				



## **05 Virtuoso** Easy-to-Use Operation Software

#### Image Save & Export -



Line	Box	Circle	Poly	Select
Del	Angle	Ruler	Marea.	n the second sec

#### Image Parameter Control

C Rot	GA X	GA Y	Contras:	Crisht
Cignator1	St smator2	[+] Focus		



EMCRAFTS



Various Image Formats JPEG, TIFF, BMP, PNG



Observation Mode Focus Window Mode TV Mode Slow Scan Mode Photo Mode 

#### Automatic Functions



#### Vacuum Control & Status Monitor

Stop	Foc Win	Slow
	<ul> <li>800 × 600 , 6</li> <li>960 × 720 , 5</li> <li>1024 × 768 ,</li> </ul>	19 sec
Photo	🔵 3200 x 2400	, 110 sec
💿 SED 🛛 🅚	BSED	

#### **Observation Mode Selection**



Automatic Functions Filament/Bias Brightness/Contrast Gun Alignment Focus Stigmator

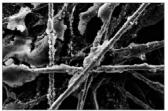


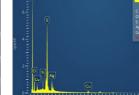
User Friendly Functions Multi-User environment Wobble Filament burn-out alarm Customizable annotation

## **06 Optional Device**

### **1. EDS SYSTEM**

- LN2-free operation, Silicon Drift Detector.
- Detects elements from Be(4) to Cf(98).
- Premium Resdution of 129 eV is available.
- Quantitative Analysis, Qualitative Analysis, Multi-Point Analysis, LineScan, Mapping.
- EDS Maker: Oxford, Thermo, Bruker, EDAX, Evex.

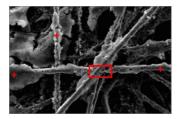




Qualitative Analysis

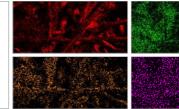
Element	Line	Apparent	k Ratio	Wt%	Wt%	Standard	Factory	Standard
	Туре	Concentration			Sigma	Label	Standard	Calibration
								Date
C	K	6.67	0.06666	72.81	0.42	C Vit	Yes	
	series							
0	K	2.32	0.00782	19.76	0.42	SiO2	Yes	
	series							
Si	K	0.05	0.00037	0.07	0.01	SiO2	Yes	
	series							
s	к	2.72	0.02340	4.42	0.06	FeS2	Yes	
	series							
Cu	к	0.45	0.00451	0.78	0.05	Cu	Yes	
	series							
Ag	L	1.18	0.01185	2.16	0.06	Ag	Yes	
	series							
Total:				100.00				

SEM Image



Point and Area Analysis





Quantitative Analysis

Mapping

### **2. ION SPUTTER COATER**



- Operating principle : Top Electrode discharge system
- Ionization power : ~50mA(Max : 500V)
- Target : 50mm(Ø) x 0.1mm thick, Disc type(Au, Pt)
- Instrument case : 270(W) x470(D) x 385(H)
- Power requirements : 220V / Single phase AC 50/60Hz, 10A
- Weight : 22kg
- Rotary Pump : 16L/min[at 60Hz]

### **3. BSE Defector**

- Semiconductor Type, 4 Channel Detector.
- BSE detector make it possible that sample with non-coating is observable and the boundary interface of alloy sample can be disentangled.



SE Image

BSE Detector

### 4. Holder



Multi Holder for 7 pin Stubs

### 5. Filament

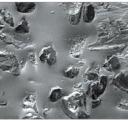




LaB<sub>6</sub> Filament

Factory-Centered Filament Cartridge

### 





BSE Image



45° Pin Stub Holder



Set Screw Vise

### 6. Critical Point Dryer

- Critical point dryer is an instrumental device which is used to preprocess biological specimens such as plants, insect, liver tissue, nerve cell, brain tissue etc.
- At critical point, the specimen is dried using CO<sub>2</sub>. The original shape of specimen would be maintained and analyzed without causing surface tension by moisture and necrosis of biological tissue by dehydration.



### 7. Freeze Dryer

- Freeze dryer is to fix, dehydrate biological specimen with minimal shrinking and deformation.
- Electronic temperature control ranging from 0°C to 40°C. Rapid adjustment of temperature,10 minutes for adjustment from 40  $^{\circ}$ C to 5  $^{\circ}$ C.

### 8. Cool Stage

Cool stage offers a flexible heating/cooling to observe biological specimen. Biological specimen can be observed using cool stage with minimal dehydrationand deformation at lower temperature. Easily damaging Specimen by E-beam is also observable using cool stage.

### 9. Polishing Machine



#### The top of the range automatic polishing machines.

- Powerful Fitted with powerful motors controled by a frequency controller!
- Reproducible Built-in memory stores all your polishing processes!
- All the settings are completely adjustable Efficent and programmable!
- Design and touch pad control! • Simple
- Intelligent All the Technological experience goes into the most complete polishing machine on the market!

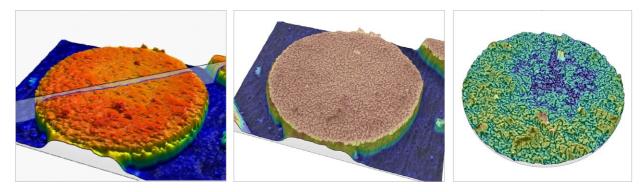
### **10. Mounting Machine**

Emcrafts offers super short mounting times and maximum user-friendliness. Speed is further improved by using the optional dosing system.



### 11. 3D Reconstruction S/W

• Many nano-scale require depth information bet most optical microscope and scanning electron microscope haven't delivered successful solutions so far. EmCrafts Products wupplies state-of-the-art 3D restruction software which is capable of 3D imaging from multiple images at different angles or illuminations which can replace expensive solutions such as atomic force microscope.



### 12. More advanced applications are available

- EBSD(Electron Back Scattered Diffraction)
- WDS(Wavelength Dispersive Spectroscopy)
- CL(Cathodoluminescence) Imaging
- Chamber Camera
- Raman Spectroscopy
- Etc.

### M EMCRAFTS

#### Powerful hydraulic system

• Fast heating and cooling using new heating and cooling technology Available dual sample products with intermediate piston • Two cylinder sample products available in different sizes • Requests for up to 4 sample products at once are possible • 18 preset functions according to resin and mold size Good sample product system with preheating • Faster cycle with optimized cooling system.